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STRUCTURE AND CHARACTERISTICS OF MULTILAYER  
(GaAs-Al<sub>x</sub>Ga<sub>1-x</sub>As) DOUBLE HETEROSTRUCTURE

INJECTION LASERS

by

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SYNOPSIS

Double heterostructure (DH) injection lasers, composed of three layers, n-Al<sub>x</sub>Ga<sub>1-x</sub>As, p-GaAs and p-Al<sub>x</sub>Ga<sub>1-x</sub>As, were reported by Panish et al.<sup>1</sup> and Alferov et al.<sup>2</sup> At room temperature these DH lasers showed much lower threshold current densities ( $J_{th}$ ) than any of the homostructure or the single heterostructure (SH) laser diodes.<sup>3-6</sup> In the best group of diodes,  $J_{th}$  were as low as about 1 kA/cm<sup>2</sup> for fully internally reflecting modes and about 2 kA/cm<sup>2</sup> for Fabry-Perot modes.<sup>7</sup> However, Al<sub>x</sub>Ga<sub>1-x</sub>As has higher thermal resistance than GaAs. In order to obtain a high duty cycle or a continuous operation at high temperatures near room temperature, a multilayer structure was produced. This structure includes a thin (~1μm) p-GaAs active layer (second layer), a thin (1 ~2μm) p-Al<sub>x</sub>Ga<sub>1-x</sub>As layer (third layer) and a thin (1 ~2μm) p-GaAs layer (fourth layer).<sup>7</sup> The thin third layer provides a relatively low thermal resistance pass between the active region and a heat-sink which is attached on the top of the fourth layer while providing the required optical and carrier confinement. The purpose of the fourth layer is to produce a low resistance ohmic contact on the diode.

The fabrication and the characteristics of these multilayer structure laser diodes will be discussed.

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